

Application No. 09/715,935

AMENDMENT TO THE CLAIMS

A detailed listing of all claims that are, or were, in the present application, irrespective of whether the claim(s) remains under examination in the application are presented below. The claims are presented in ascending order and each includes one status identifier. Those claims not cancelled or withdrawn but amended by the current amendment utilize the following notations for amendment: 1. deleted matter is shown by strikethrough for six or more characters and double brackets for five or less characters; and 2. added matter is shown by underlining.

1.-17. (Canceled).

18. (Currently Amended) A method of coating a substrate, the method comprising:
reacting a reactant stream within a flow by directing a radiation beam at the reactant stream to produce within the flow a product stream comprising particles downstream from the radiation beam, wherein the particles are produced by the reaction, wherein the flow passes through the radiation beam, and wherein the reaction is driven by energy from the radiation beam;
directing the flow of the product stream to a substrate; and
moving the substrate relative to the flow of the product stream to coat the substrate with a coating comprising fused particles.

19. (Original) The method of claim 18 wherein the radiation beam is generated by a light source.

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20. (Original) The method of claim 18 wherein the radiation beam is generated by a laser.
21. (Original) The method of claim 18 further comprising pumping on the reaction chamber to maintain flow through the reaction chamber.
22. (Original) The method of claim 18 wherein the reactant stream is elongated in a direction along the propagation of the radiation beam.
23. (Original) The method of claim 18 wherein the substrate is mounted on a stage that moves relative to a product stream.
24. (Original) The method of claim 23 wherein the reactant stream is elongated in a direction along the propagation of the radiation beam to produce a line of product particles that are simultaneously deposited on the substrate and wherein relative movement of the stage sweeps the line across the substrate.
25. (Original) The method of claim 23 further comprising moving the substrate from the path of the reactant stream and placing another substrate in the path of the product stream.
26. (Original) The method of claim 18 wherein the reactant stream is elongated and wherein a line of light propagates to intersect the elongated reactant stream.
27. (Currently Amended) ~~The method of claim 18~~ A method of coating a substrate, the method comprising:

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reacting a reactant stream within a flow by directing a radiation beam at the reactant stream to produce within the flow a product stream comprising particles downstream from the radiation beam, wherein the particles are produced by the reaction, wherein the flow passes through the radiation beam, and wherein the reaction is driven by energy from the radiation beam;
directing the flow of the product stream to a substrate; and
moving the substrate relative to the flow of the product stream to coat the substrate,
wherein the reactant inlet moves relative to the substrate such that motion of the reactant inlet sweeps the product particles across the substrate.

28. (Original) The method of claim 18 wherein the product stream passes through a conduit prior to reaching the substrate and wherein the conduit moves relative to the substrate with motion of the conduit sweeping the product particles across the substrate.

29. (Original) The method of claim 18 wherein an external field is applied to direct the product stream.

30. (Original) A method of forming a glass coating comprising heating a particle coating at a temperature and for a period of time sufficient to fuse the particles into a glass and where the particle coating is formed according to the method of claim 18.

31. (Original) A method of forming an optical component on a substrate surface, the method comprising removing a portion of a glass coating formed according to the method of claim 30 to form the optical component.

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32. (Original) The method of claim 31 wherein the removing of a portion of the glass coating is performed by photolithography.

33. (Currently Amended) A method of coating a substrate comprising:
generating, within a flow, a reactant stream with a cross section perpendicular to the propagation direction characterized by a major axis and a minor axis, the major axis being at least a factor of two greater than the minor axis;
reacting the reactant stream to form a product stream of particles within the flow;
[[and]]
directing the flow of the product stream of particles to a substrate; ~~and, wherein flow of the product stream is maintained other than by pumping on the substrate~~
moving the substrate relative to the flow of the product stream to coat the entire substrate in one pass.

34. (Original) The method of claim 33 wherein at least about 25 grams per hour are deposited onto the substrate.

35. (Original) The method of claim 33 wherein the reaction is driven by a light beam.

36. (Original) The method of claim 33 wherein the major axis is at least a factor of ten greater than the minor axis.

37. (Original) The method of claim 33 wherein the flow of the stream of particles is maintained by momentum of the product stream.

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38. (Original) The method of claim 33 wherein the flow of the stream of particles is maintained by pumping out a chamber and wherein the substrate is located within the chamber.

39-61. (Canceled)

Please add the following new claims.

62. (New) The method of claim 27 wherein the radiation beam is generated by a laser.

63. (New) The method of claim 27 further comprising pumping on the reaction chamber to maintain flow through the reaction chamber.

64. (New) The method of claim 27 wherein the reactant stream is elongated in a direction along the propagation of the radiation beam.

65. (New) The method of claim 27 wherein the substrate is mounted on a stage with a thermal control feature so that the stage can be heated.

66. (New) The method of claim 27 wherein the substrate is mounted on a stage with a thermal control feature so that the stage can be cooled.

67. (New) A method of coating a substrate, the method comprising:
reacting a reactant stream within a flow by directing a radiation beam at the reactant stream to produce within the flow a product stream comprising particles downstream from the radiation beam, wherein the particles are produced by

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the reaction, wherein the flow passes through the radiation beam, and
wherein the reaction is driven by energy from the radiation beam;
directing the flow of the product stream to a substrate;
moving the substrate relative to the flow of the product stream to coat the substrate
in a controlled way over a selected portion of the substrate less than the
entire substrate surface; and
heating the coated substrate to form a patterned dense coating material.

68. (New) The method of claim 67 wherein the radiation beam is generated by a laser.
69. (New) The method of claim 67 further comprising pumping on the reaction chamber to maintain flow through the reaction chamber.
70. (New) The method of claim 67 wherein the reactant stream is elongated in a direction along the propagation of the radiation beam.
71. (New) A method of coating a substrate comprising:
generating a first product stream within a flow produced by a chemical reaction of a first reactant stream wherein the chemical reaction is driven by a light beam;
depositing the first product stream on a moving substrate to form a first coating;
generating a second product stream within a flow produced by a chemical reaction of a second reactant stream wherein the chemical reaction is driven by a light beam;
depositing the second product stream on the moving substrate to form a second coating; and
heating the substrate to form a first dense coating and a second dense coating.

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72. (New) The method of claim 71 wherein the heating of the substrate comprises a first heating of the substrate after depositing the first coating and before depositing the second coating to form the first dense coating and a second heating of the substrate after forming the second coating to form the second dense coating.

73. (New) The method of claim 71 wherein the heating of the substrate is performed after deposition of the first coating and the second coating so that the first dense coating is not formed prior to the deposition of the second coating.